



# **Hypervalent Iodine** Compounds

# **Hypervalent Iodine Compounds**

As Japan is not blessed with abundant natural resources, it is dependent on the importation of the majority of its raw materials from overseas. However, Japan can be proud of its production of iodine, where it is a leading world manufacturer. The present situation in Japan is that the produced and exported iodine products are low value-added products, and thus Japan still relies on the United States and Europe for importation of high value-added iodine products such as X-ray contrast medium or photosensitive agent for photographic film.

lodine is atomic number 53, in the 5th period, Group VIIa, halogens of the periodic table. Iodine is a large-sized halogen element, easily polarizable, and low in electronegativity. It forms hypervalent iodine compound beyond the octet rule by readily extending its valence. For example, a hypervalent iodine compound with three ligands is a 10-I-3 type compound as shown in the figure. The central iodine atom forms a plane with two lone pairs and one s-bond, and furthermore, this iodine atom coordinates two ligands with larger electronegativity in an apical position orthogonal to the plane resulting in the formation of a linear three center-four electron bond. The I-L bond in the apical position is longer than the covalent bond. For example, the I-O bond lengths in (diacetoxyiodo)benzene (PhI(OAc)<sub>2</sub>, [10330]) are longer than the sum of their covalent bond radii (1.99Å) and these bond lengths have a range of 2.15 - 2.16Å.

The stability and reactivity of hypervalent iodine compounds exhibit a greater dependence on the character of hypervalent bonds in the apical position. The hypervalent bonds in the apical position are easily cleaved, and the cleavage causes trivalent iodine with 10 electrons to be reduced to monovalent iodine of a more stable octet structure. For this reason it exhibits good elimination and oxidation rates and finds application in organic syntheses.<sup>1)</sup>

#### Oxidizing Agents

ABBX [A2678] is a highly active trivalent iodine compound, developed by Togo *et al.*<sup>3)</sup> A2678 oxidizes benzylic alcohols and aliphatic secondary alcohols to the corresponding aldehydes and ketones in good yields from simple extraction of the reaction mixture. 5-Bromo-2-iodobenzoic acid, formed as a co-product of this reaction, can be recovered by acidification of the aqueous layer.

The most common of the trivalent iodine compounds, (diacetoxyiodo)benzene [10330] has been supported on a polymer. For example, Togo and co-workers have demonstrated several oxidation reactions using poly[4-(diacetoxyiodo)-styrene] [P1415]<sup>3)</sup>

(TBDPSO = tert-Butyldiphenylsilyloxy)

P1415 can selectively oxidize primary alcohols to aldehydes, and secondary alcohols to ketones under mild conditions in the presence of TEMPO. After the reaction, the by-product, poly(4-iodostyrene), can be recovered by filtration, re-oxidized with peracetic acid, and reused. Therefore P1415 is expected to be used as environmentally-friendly oxidation reagent in the future.

#### Fluorinating Agents

1-Fluoro-3,3-dimethyl-1,2-benziodoxole [F0957] is an air- and moisture-stable compound developed by Stuart *et al.*<sup>4)</sup> F0957 is used as an electrophilic fluorinating agent for a  $\alpha$ -monofluorination of  $\beta$ -ketoesters in the presence of triethylamine trihydrofluoride. In this reaction, a difluorination reaction occurs by increasing the amounts of F0957 with heating at 60 °C. On the other hand, Szabó *et al.* have reported a difluorination reaction of F0957 with styrene derivatives.

They suggest that the reaction proceeds through the formation of a phenonium ion intermediate based on a deuteriumisotope-labelling experiment.

#### Monofluorination of β-ketoesters

$$\begin{array}{c} \text{F-I-O} \\ \text{[F0957] (2 equiv.)} \\ \text{Et}_3\text{N-3HF (2.7 equiv.)} \\ \text{CH}_2\text{Cl}_2 \\ \text{40 °C, 24 h} \\ \text{Ph} \\ \text{OEt} \\ \text{F} \\ \text{F} \\ \text{(a)} \\ \text{(b)} \\ \text{a : b = 89 : 6 (^1H NMR)} \\ \text{Y. 63\% (isolated)} \end{array}$$

#### Difluorination of styrene derivatives

### Trifluoromethylating Agents

Togni Reagent [T2624] is an electrophilic trifluoromethylating agent developed by Togni and co-workers, which reacts with  $\beta$ -keto esters and  $\alpha$ -nitro esters to introduce a trifluoromethyl group on their  $\alpha$ -carbons. T2624 also reacts with thiols and primary- and secondary phosphines to generate trifluoromethyl sulfides and trifluoromethyl substituted phosphines respectively. T2624 can be applicable to various substrates.  $^{5}$ 

Togni Reagent II [T3014] is also an electrophilic trifluoromethylating agent, which was developed by Togni *et al.* T3014 enables it to trifluoromethylate various substrates, as well as Togni Reagent. In particular, it has been reported that the reaction of T3014 and olefins affords the corresponding allylic trifluoromethylated compounds.<sup>6)</sup>

\*T3014 contains diatomaceous earth because of reducing explosibility.

### Ethynylation Reagents

Ochiai and co-workers have developed alkynyliodonium tetrafluoroborate [E0467] prepared from alkynylsilanes and iodosobenzene in the presence of BF<sub>3</sub> and they reported its efficacy as electrophilic ethynylation reagents. <sup>7)</sup>

When E0467 was reacted with enolates, alkylidene carbene was generated as an intermediate, and subsequently, an ethynylated product was obtained via 1,2-hydrogen rearrangement of the α-hydrogen. This reaction proceeded under room temperature, and afforded ethynylated products in high yields. As for other electrophilic ethynylation reagents, ethynyl lead triacetate has been exploited, which is prepared from ethynyl(trimethyl)stannane and lead tetraacetate. However, preparation of this reagent requires the use of heavy metal compounds, which make it an unattractive procedure. The ethynylation procedure using this reagent requires careful control of the reaction conditions. The ethynylation method using E0467 has been at the center of attention in many fields, as this method does not use highly toxic heavy metal compounds, and the reaction proceeds under mild conditions.

#### Benzyne Precursors

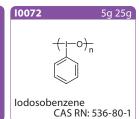
Kitamura and co-workers have reported mild benzyne generation method using TMS-phenyliodonium compound [P1620].<sup>8)</sup> According to the report, benzyne can be efficiently generated by treating P1620 with Bu<sub>4</sub>NF. P1620 is the excellent benzyne precursor which needs neither high temperature condition nor strong basic treatment in order to generate benzyne.

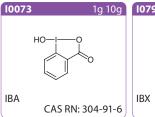
#### References

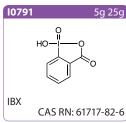
- A. Varvoglis, Synthesis 1984, 709; P. J. Stang, V. V. Zhdankin, Chem. Rev. 1996, 96, 1123; V. V. Zhdankin, P. J. Stang, Chem. Rev. 2002, 102, 2523.
- 2) M. linuma, K. Moriyama, H. Togo, Eur. J. Org. Chem. **2014**, 772.
- 3) H. Togo, S. Abe, G. Nogami, M. Yokoyama, *Bull. Chem. Soc. Jpn.*1999, *72*, 2351; H. Togo, K. Sakuratani, *Kagaku to Kogyo*(*Chemistry and Chemical Industry*) 2002, *55*, 1018; H.Togo, K. Sakuratani, *Synlett* 2002, 1966; Tokyo Kasei Kogyo,
  Jpn. Kokai Tokkyo Koho 2003-113131.
- G. C. Geary, E. G. Hope, K. Singh, A. M. Stuart, Chem. Commun. 2013, 49, 9263; N. O. Ilchenko, B. O. A. Tasch, K. J. Szabó, Angew. Chem. Int. Ed. 2014, 53, 12897.

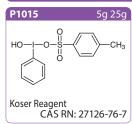
- P. Eisenberger, S. Gischig, A. Togni, Chem. Eur. J. 2006, 12, 2579; I. Kieltsch, P. Eisenberger, A. Togni, Angew. Chem. Int. Ed. 2007, 46, 754; P. Eisenberger, I. Kieltsch, N. Armanino, A. Togni, Chem. Commun. 2008, 1575.
- P. Eisenberger, S. Gischig, A. Togni, *Chem. Eur. J.* **2006**, *12*, 2579; X. Wang, Y. Ye, S. Zhang, J. Feng, Y. Xu, Y. Zhang, J. Wang, *J. Am. Chem. Soc.* **2011**, *133*, 16410.
- M. Ochiai, T. Ito, Y. Takaoka, Y. Masaki, M. Kunishima, S. Tani, Y. Nagao, J. Chem. Soc. Chem. Commun. 1990, 118; M. Ochiai, TCIMAIL, 1999, number 104, 2.
- 8) T. Kitamura, M. Yamane, J. Chem. Soc. Chem. Commun. 1995, 983; T. Kitamura, M. Yamane, K. Inoue, M. Todaka, N. Fukatsu, Z. Meng, Y. Fujiwara, J. Am. Chem. Soc. 1999, 121, 11674; T. Kitamura, M. Todaka, Y. Fujiwara, Org. Synth. 2002, 78, 104.

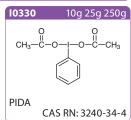
## **Oxidizing Agents**

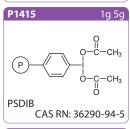




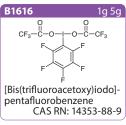


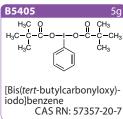


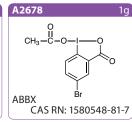


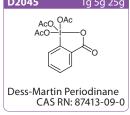




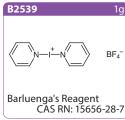


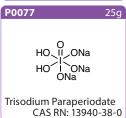




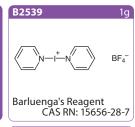


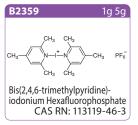




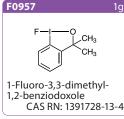




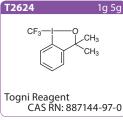


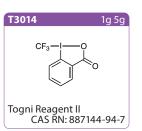


# **Fluorinating Agents**

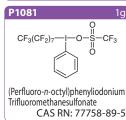




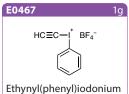




Perfluoroalkylating Agents

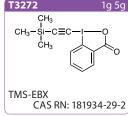


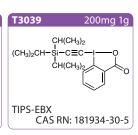
# **Ethynylation Reagents**

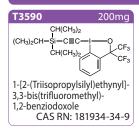


CAS RN: 127783-34-0

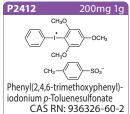
Tetrafluoroborate

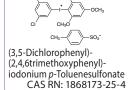




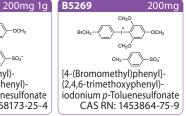


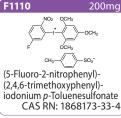


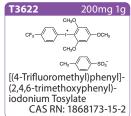


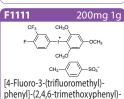


D5145



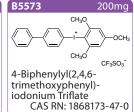




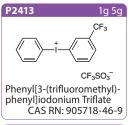


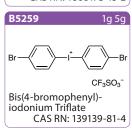
iodonium p-Toluenesulfonate

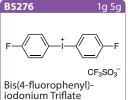
CAS RN: 1868173-29-8

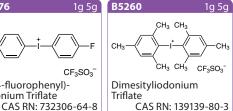


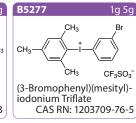




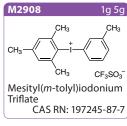


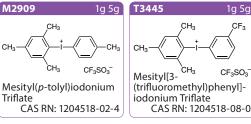


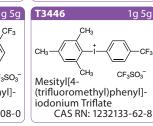


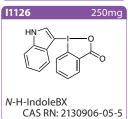




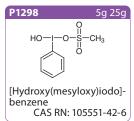




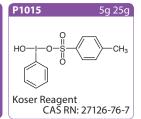




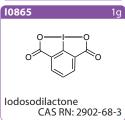




# **Tosyloxylation Reagents**



## **Condensation Reagents**

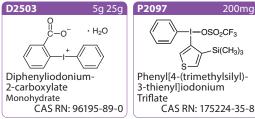


## **Benzyne Precursors**

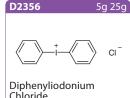


CAS RN: 164594-13-2

CAS RN: 1483-72-3







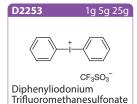


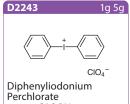


200ma

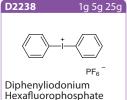
OSO<sub>2</sub>CF<sub>3</sub>

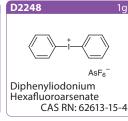
Si(CH<sub>3</sub>)<sub>3</sub>

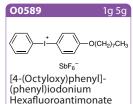




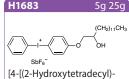








CAS RN: 66003-76-7



oxy]phenyl]phenyliodonium

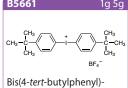
CAS RN: 139301-16-9

Hexafluoroantimonate

CAS RN: 75007-13-5

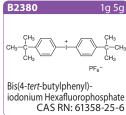


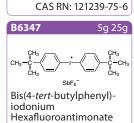
CAS RN: 5421-53-4

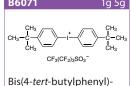


iodonium Tetrafluoroborate CAS RN: 62051-09-6

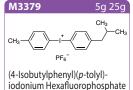
CAS RN: 58109-40-3





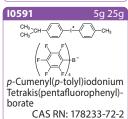


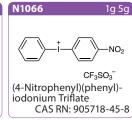
iodonium Nonaflate



(ca. 70% in Propylene Carbonate)

CAS RN: 344562-80-7



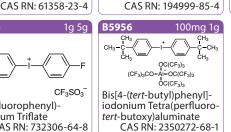


7

B5276 1g 5g ` CF<sub>3</sub>SO<sub>3</sub> Bis(4-fluorophenyl)-

CAS RN: 732306-64-8

iodonium Triflate



### **Ordering and Customer Service**

### **TCI AMERICA**

:800-423-8616 / 503-283-1681 Tel Tel :888-520-1075 / 503-283-1987 E-mail: Sales-US@TCIchemicals.com

: +49 (0)6196 64053-00 : +49 (0)6196 64053-01 

TCI EUROPE N.V.

Tel

: +32 (0)3 735 07 00

: +32 (0)3 735 07 01 E-mail: Sales-EU@TCIchemicals.com

**TCI Deutschland GmbH** 

### 梯希爱(上海)化成工业发展有限公司

Tel : 800-988-0390 / 021-67121386 : 021-6712-1385

Tokyo Chemical Industry UK Ltd.
Tel: +44 (0)1865 78 45 60
E-mail: Sales-UK@TCIchemicals.com

Tokyo Chemical Industry (India) Pvt. Ltd.
Tel: 1800 425 7889 / 044-2262 0909
E-mail: Sales-IN@TCIchemicals.com

### TOKYO CHEMICAL INDUSTRY CO., LTD.

Tel : +81 (0)3-5640-8878 E-mail : globalbusiness@TCIchemicals.com

<sup>•</sup> Chemicals itemized in this brochure are for research and testing use only. Please avoid use other than by chemically knowledgeable professionals. • Information such as listed products and its specifications and so on are subject to change without prior notice. • The contents may not be reproduced or duplicated in whole or in part without permission of Tokyo Chemical Industry Co., Ltd.